

Micro-structured multiplier concepts for single-phase detectors

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In cooperation with

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- **Goal** - combined high-sensitivity S1 & S2 detection
- **Aims** - overcome physical/technical 2-phase issues; lowering detection thresholds.
- **Potential applications** - large-volume DM experiments & more.

A.B. 2022 <https://doi.org/10.1088/1748-0221/17/08/P08002>

Martinez Lema 2023 <https://arxiv.org/abs/2308.08314>

Martinez-Lema 2023 <https://doi.org/10.1088/1748-0221/19/01/P01030>



אוניברסיטת בן-גוריון בנגב
Ben-Gurion University of the Negev



Single-phase detectors

- **No liquid-gas interface**
 - Reduced instabilities (interface ripples)
 - No delayed e^- emission or e^- transfer efficiency through interface
 - No gate-interface-anode alignment problems
 - Horizontal drift → sporadic bubbling not a concern
 - Potential improvement to the S2-only energy resolution
 - Radial TPC
 - Symmetric central cathode TPC → lower voltages needed
 - Horizontal & vertical

Challenges

- High EL and CM thresholds in LXe → amplification requires extreme electric fields
- Techniques & Technologies

Single phase with thin wires

Wire array: Talk by MULLER
Single wire: Talk by QI & NI

- ~50 years of Wires in LXe:

Derenzo PRA 1974

Masuda NIM 1979

Aprile JINST 2014

Brown JINST 2022

- So far no “practical” success
- Potential problems (for large detectors):

High fields

→ Few μm Φ wires or very high voltage

→ wires sagging, staggering

APRILE JINST 2014

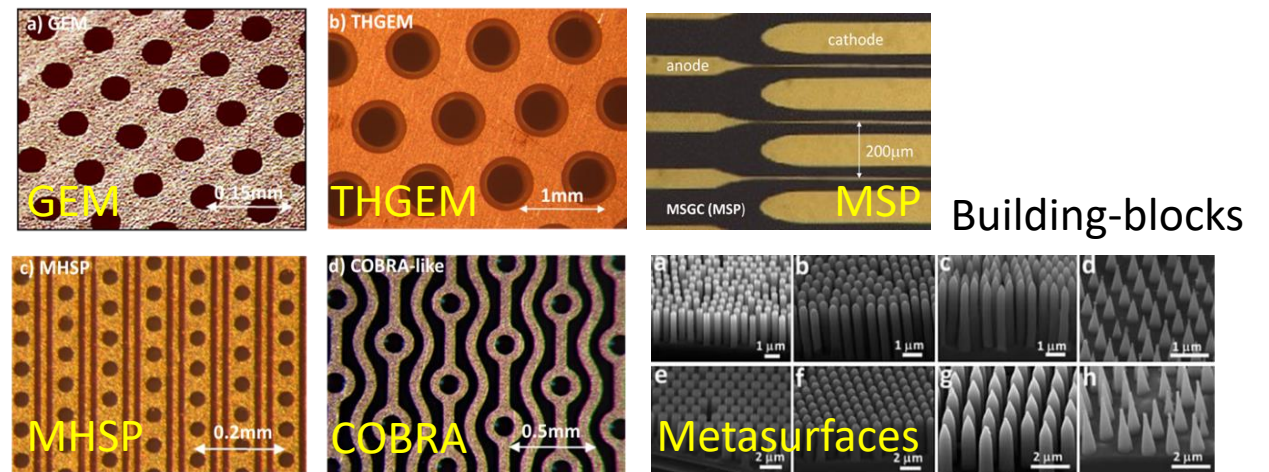
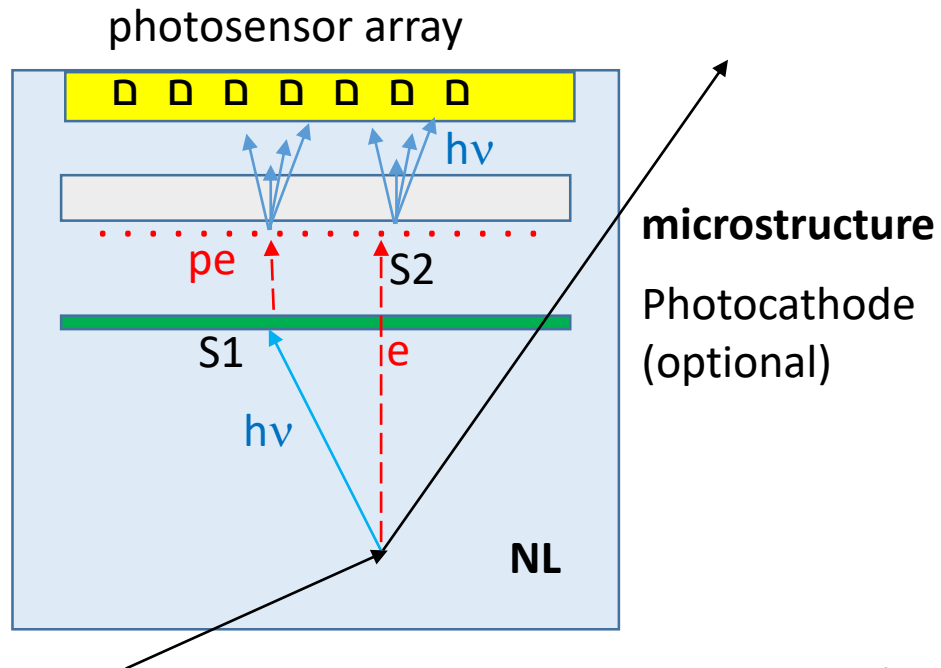
Threshold fields:

EL: ~ 412 kV/cm

CM: ~ 725 kV/cm

Single-phase liquid multiplying microstructures

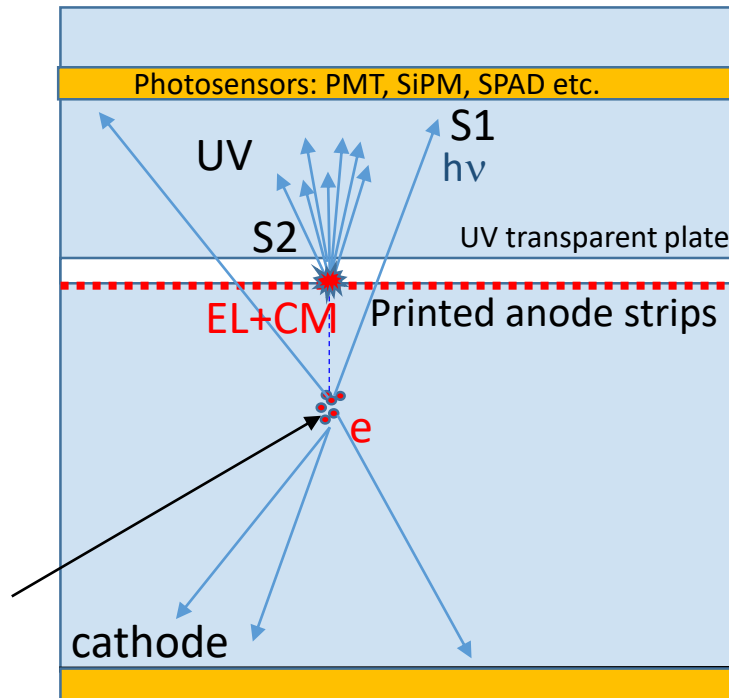
- **S2 e** (& **S1 pe** from a photocathode in NL) collected onto micro-structured electrodes: MSP, MHSP, COBRA, Metasurfaces...
- Charge multiplication (CM) & electroluminescence (EL), at high fields.
- EL & CM photons detected by near-by photosensors.
- Various configurations discussed for **e** & combined **e/pe** detection.



S2 Only
“reality”

Charge multiplication with microstructures

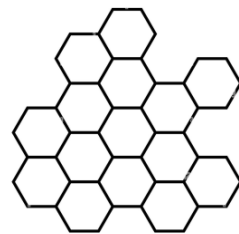
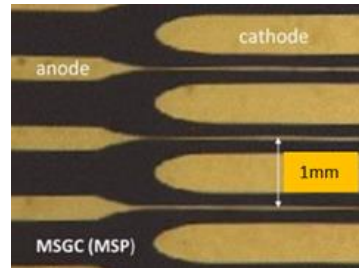
S2 detection



PMT, SiPM, SPAD etc.
or **reflective cathode**.

MSP LXe: gain 10
Policarpo et al. NIMA 1995

**Microstructure:
e.g. Micro Strip Plates**

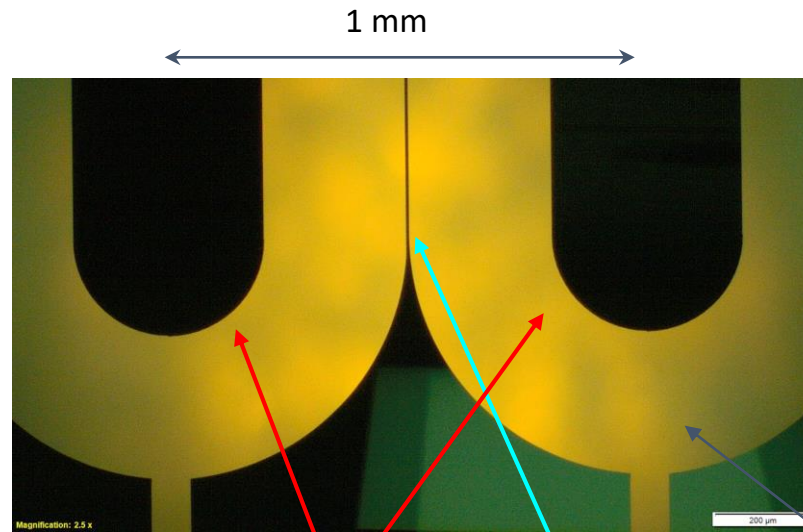
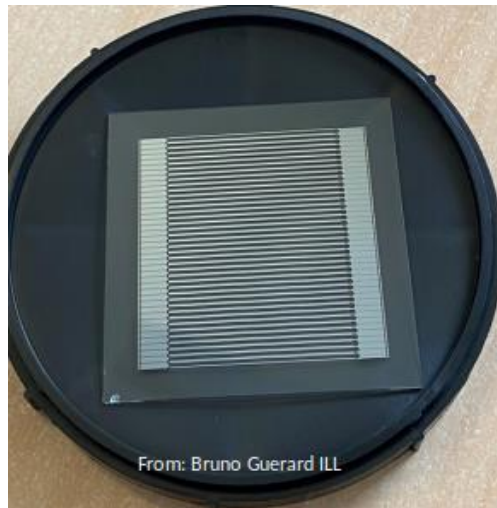


**Robust
Modular**

- Microstructure (e.g. MSP) formed on VUV-transparent substrate, with semi-transparent Ni or Cr electrodes.
- Deposited charges drift in liquid; undergo **EL & small charge multiplication (CM)** near thin (μm) anode strips (structures).
- The resulting photo-yield depends on type & configuration.
- EL+CM S2 Photons recorded above.
- S1 scintillation photons: with top & bottom photo-sensors (or reflective cathode)

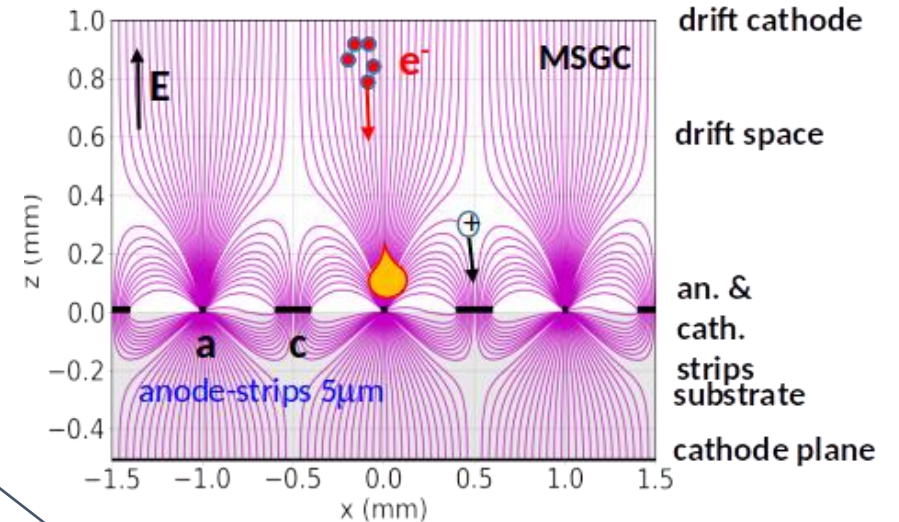
Microstrips

- First proposed by **Oed in 1988** for the MicroStrip Gas Chamber (MSGC)
- Thin strips deposited on a substrate (ideally VUV-transparent)
- Original design: cathode and anode strips interleaved



cathode strips

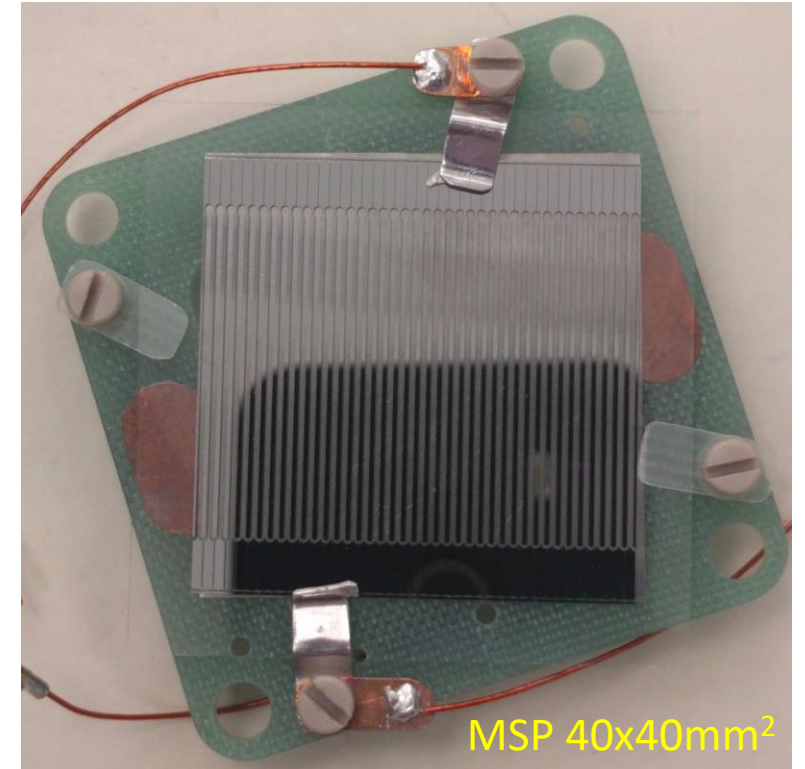
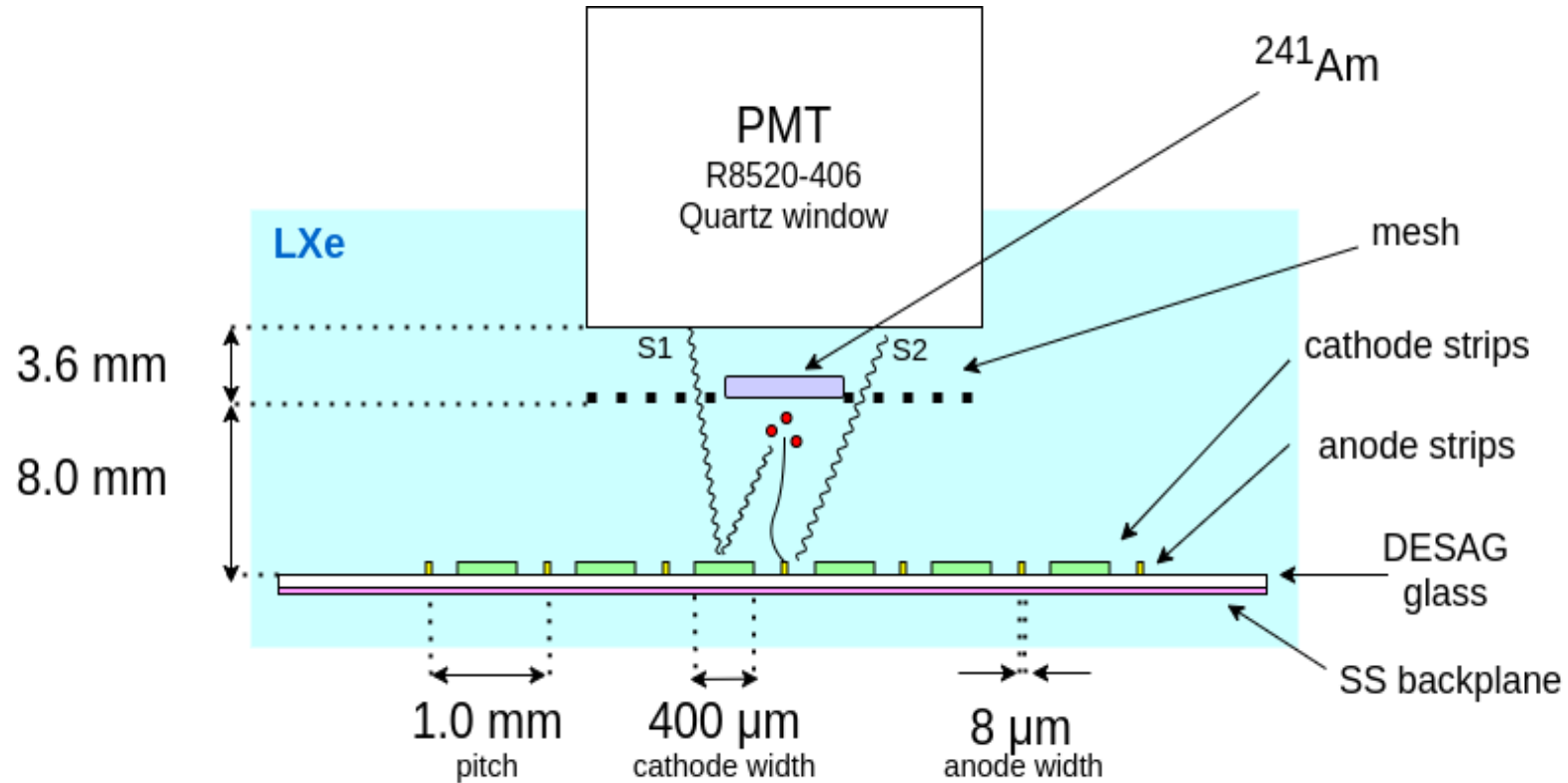
anode strip



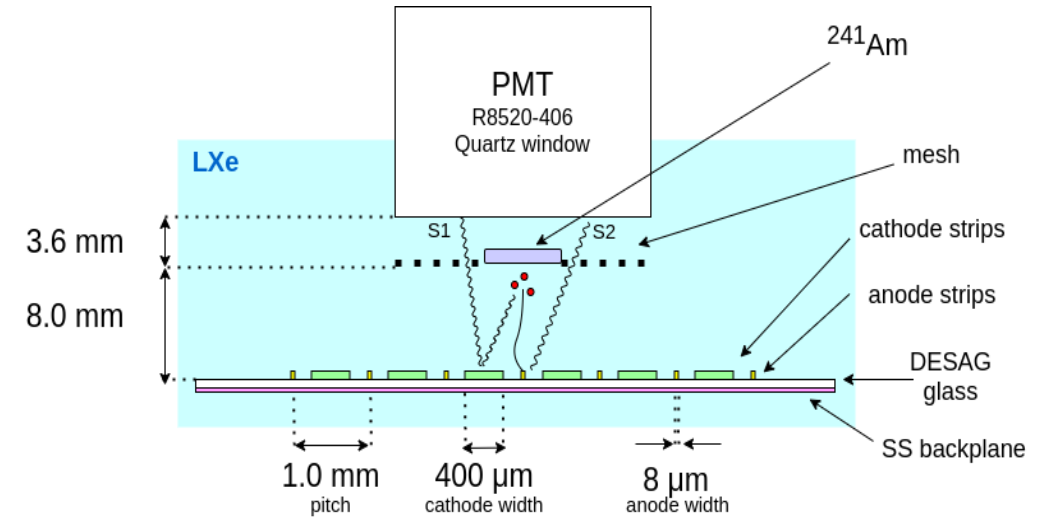
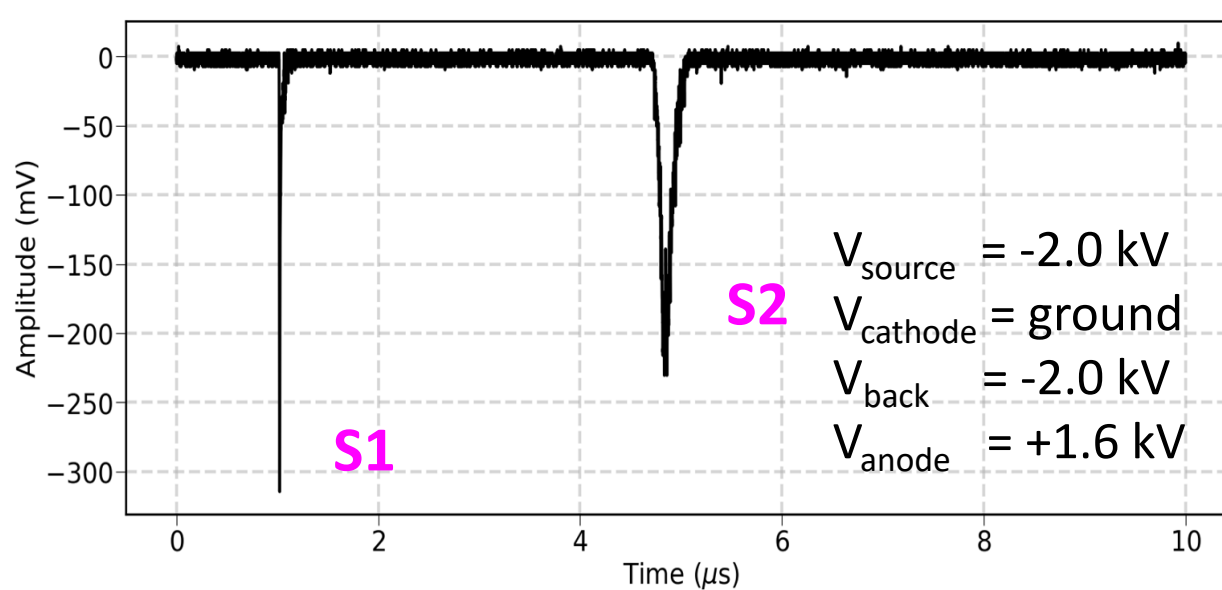
light seen through the substrate

Microstrip multiplier setup

Martinez-Lema 2023 <https://arxiv.org/abs/2308.08314>



A typical PMT waveform



$$\Omega \sim 10.5 \%$$

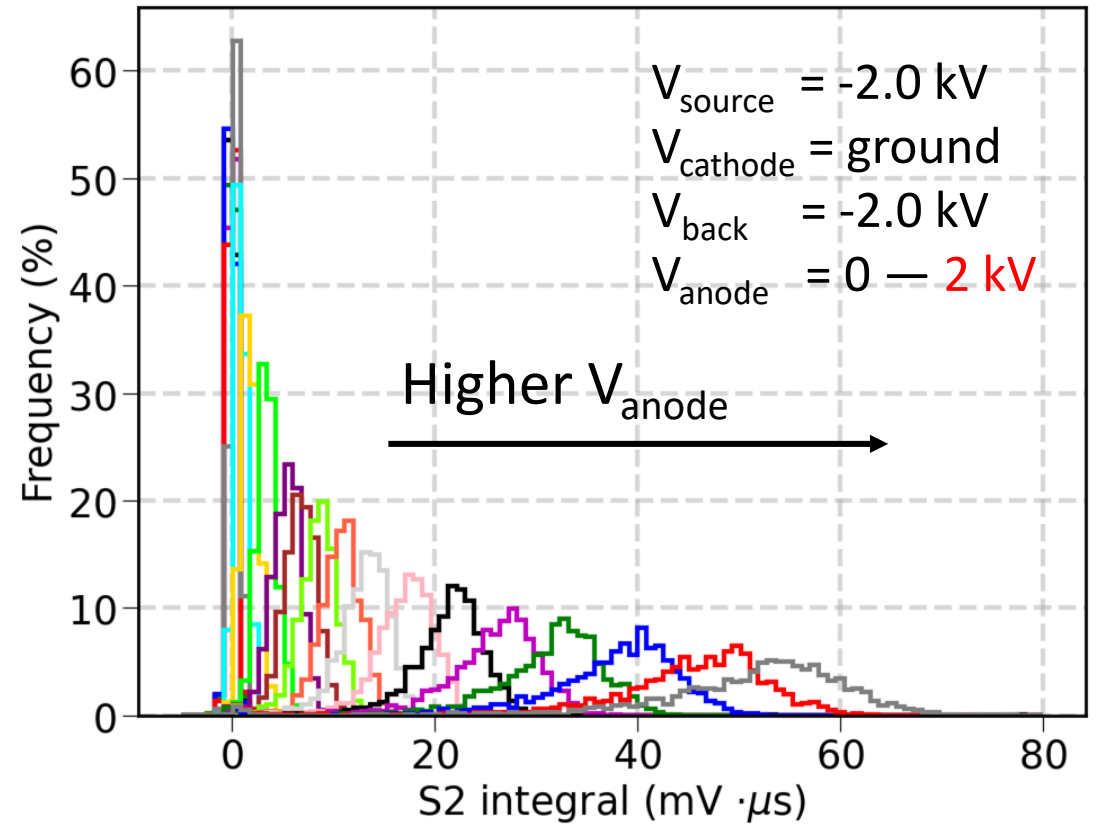
$$T \sim 81\%$$

$$QE \sim 28\%$$

$$N_{ie} \sim 15500 \sim 2.5 \text{ fC}$$

Integrated S2 signal

- PMT waveform integrated on fixed S2 window
- Integral of S2 increases with V_{anode}
- Max $V_{\text{anode}} = 2 \text{ kV}$ due to anode-to-cathode discharges
- EL threshold @ $V_{\text{anode}} \sim 500 \text{ V}$



Light yield

- Conversion to pe's based on in-situ PMT calibration

- Light yield @ $V_{\text{anode}} = 2 \text{ kV}$

$$\text{LY} = 33 \text{ ph/ie}$$

$$\text{LY} = \frac{S2}{\frac{\Omega}{4\pi} \cdot T \cdot QE_{PMT} \cdot N_{ie}}$$

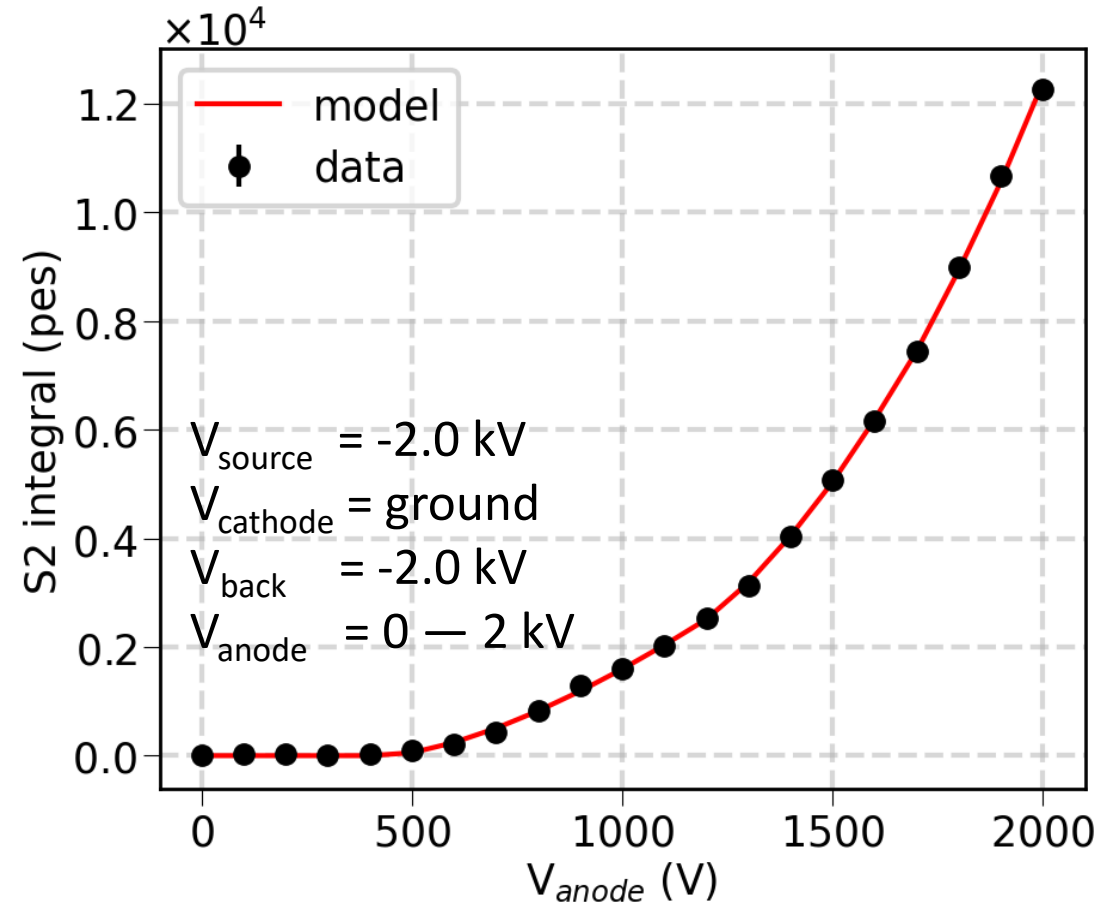
← mesh transparency ← from alpha particles

$\Omega \sim 10.5 \%$

$T \sim 81\%$

$QE \sim 28\%$

$N_{ie} \sim 15500 \sim 2.5 \text{ fC}$



Data fitted to the a CM & EL model ([APRILE 2014](#))

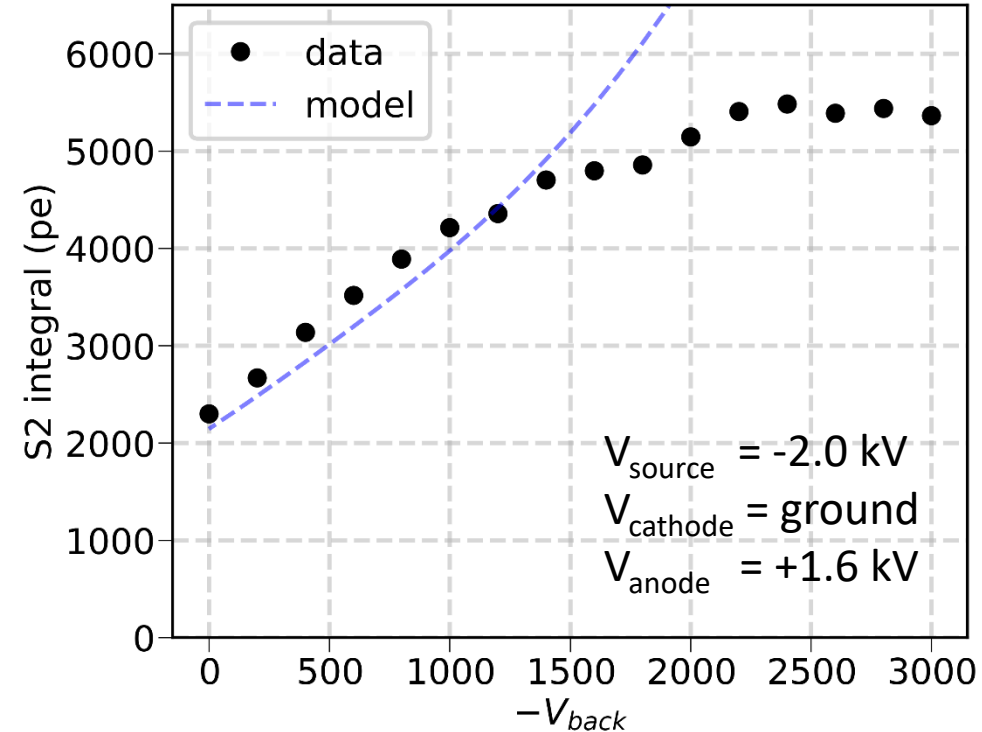
→ EL threshold (θ_4) $\sim 465 \text{ kV/cm}$

→ CM threshold (θ_2) $\sim 785 \text{ kV/cm}$

→ CM $\sim \text{x3 @ 2 kV}$

In agreement with [Aprile 2014](#) (412/725 kV/cm)

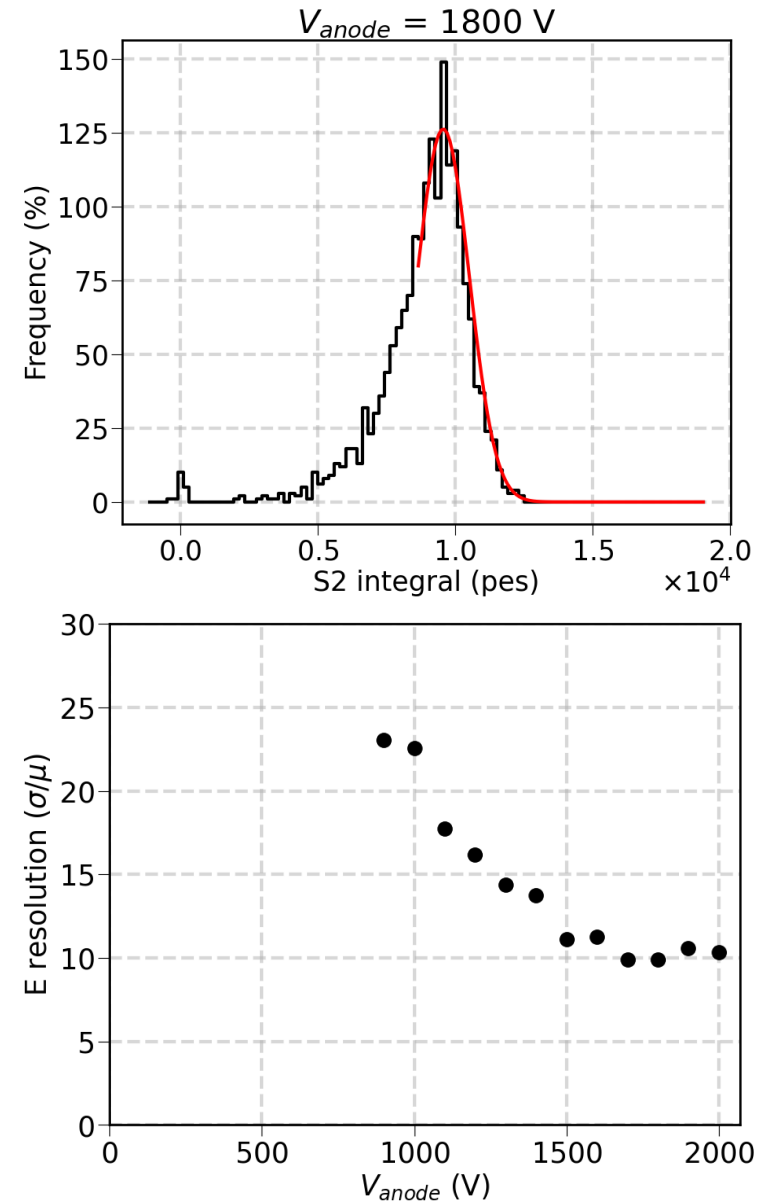
Backplane bias



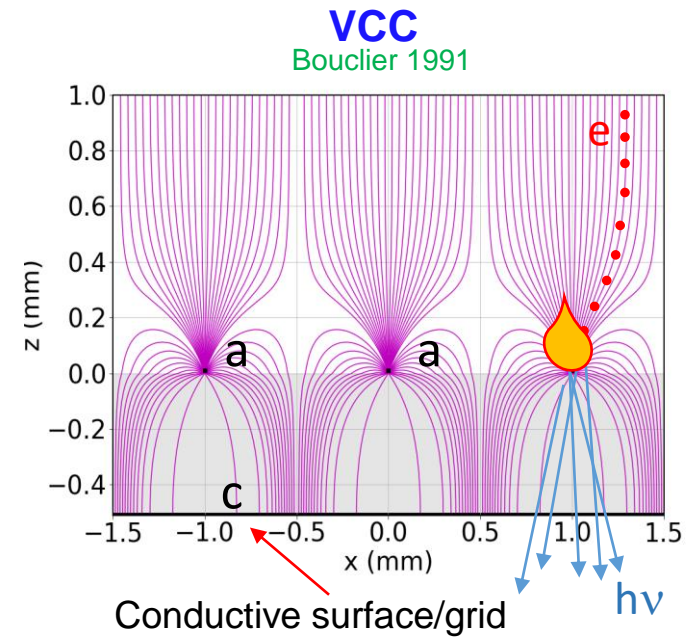
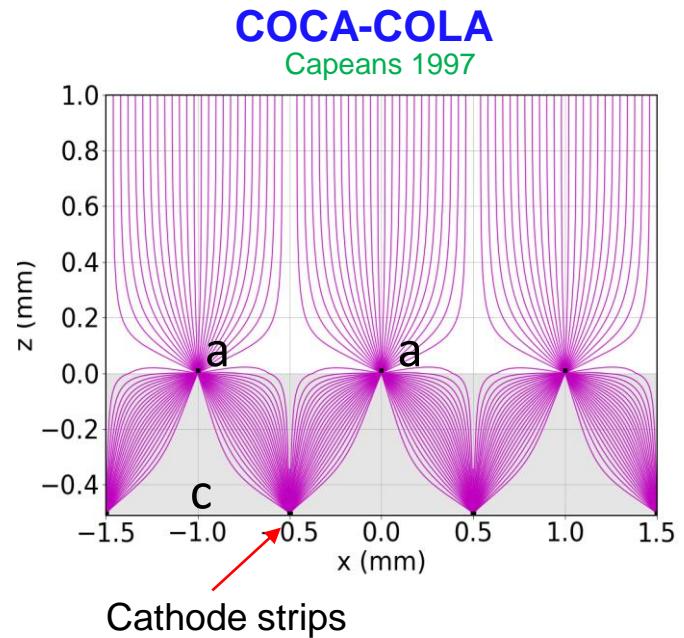
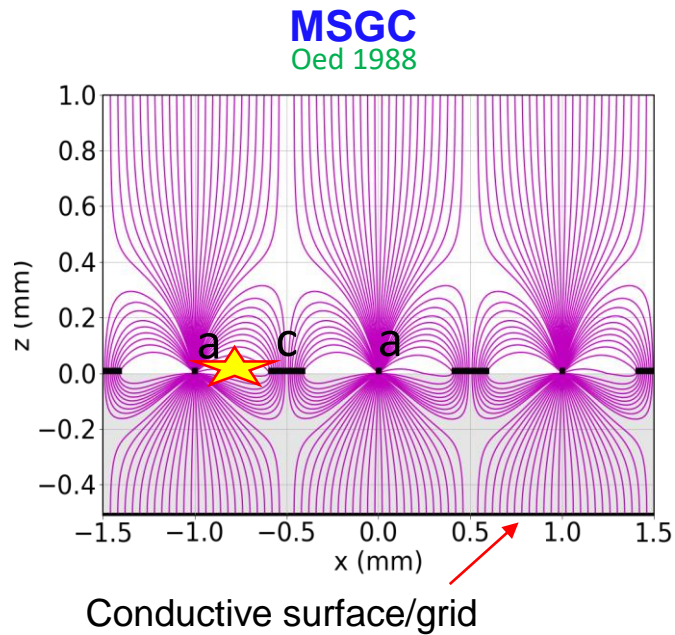
The discrepancy between data and finite-element COMSOL computations plus EL & CM model (Aprile 2014): might be due the nature of the glass substrate (slightly conductive?)

Energy resolution

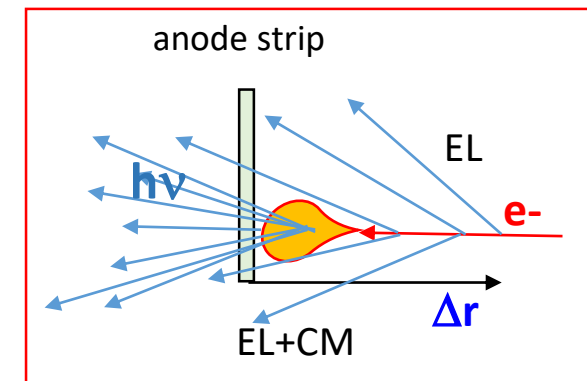
- Gaussian fit to the high-energy side
- $\sigma/\mu = 9.9\% @ 1800\text{ V}$
- Similar to the results obtained with $10\ \mu\text{m}$ wires by [Aprile 2014](#)
- Can be improved with other configurations



Prospects: MSGC vs COCA-COLA vs VCC



- MSGC has the best field configuration
But operation (discharge limit) is limited to $\sim 2\text{kV}$ a-to-c
- COCA-COLA & VCC can operate at higher V without discharges
→ higher expected photoyields



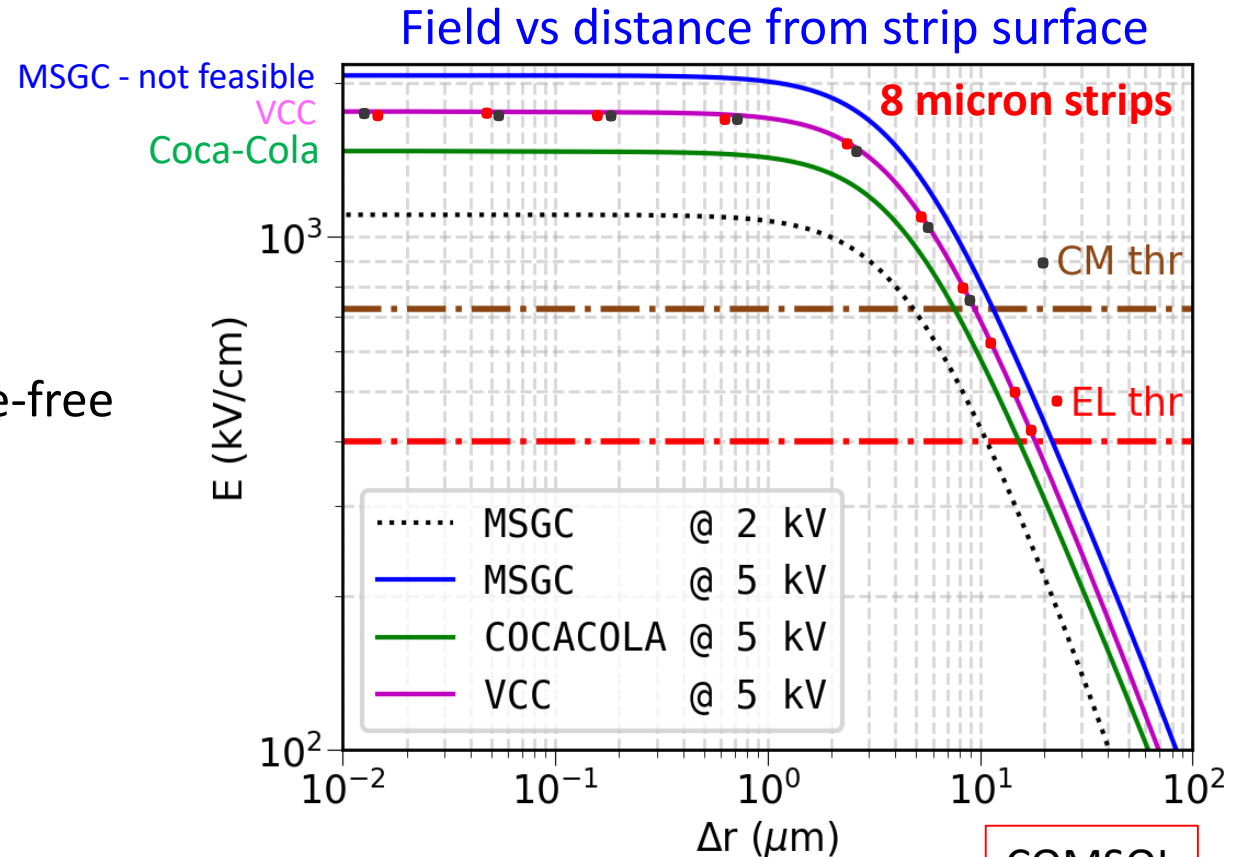
Field vs Δr : MSGC vs COCA-COLA vs VCC

- MSGC: the best field configuration
- But operation is limited to ~ 2 kV a-to-c
- COCA-COLA & VCC : higher potentials discharge-free
 - Higher e^- multiplication & light yields

Model predictions @ $V_{\text{anode}} 5\text{kV}^*$:

- COCA-COLA potential ~ 180 photons/e
- VCC potential ~ 550 photons/e

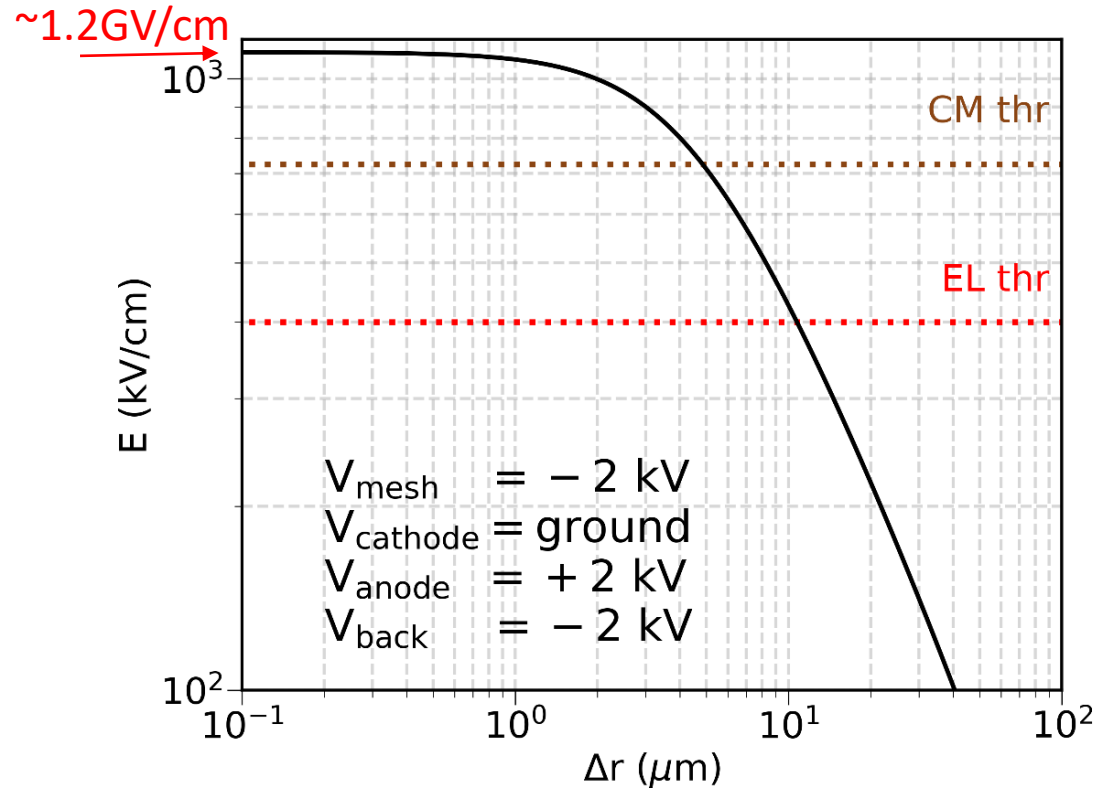
* $V_{\text{anode}} = 5\text{kV}$ taken as feasible example



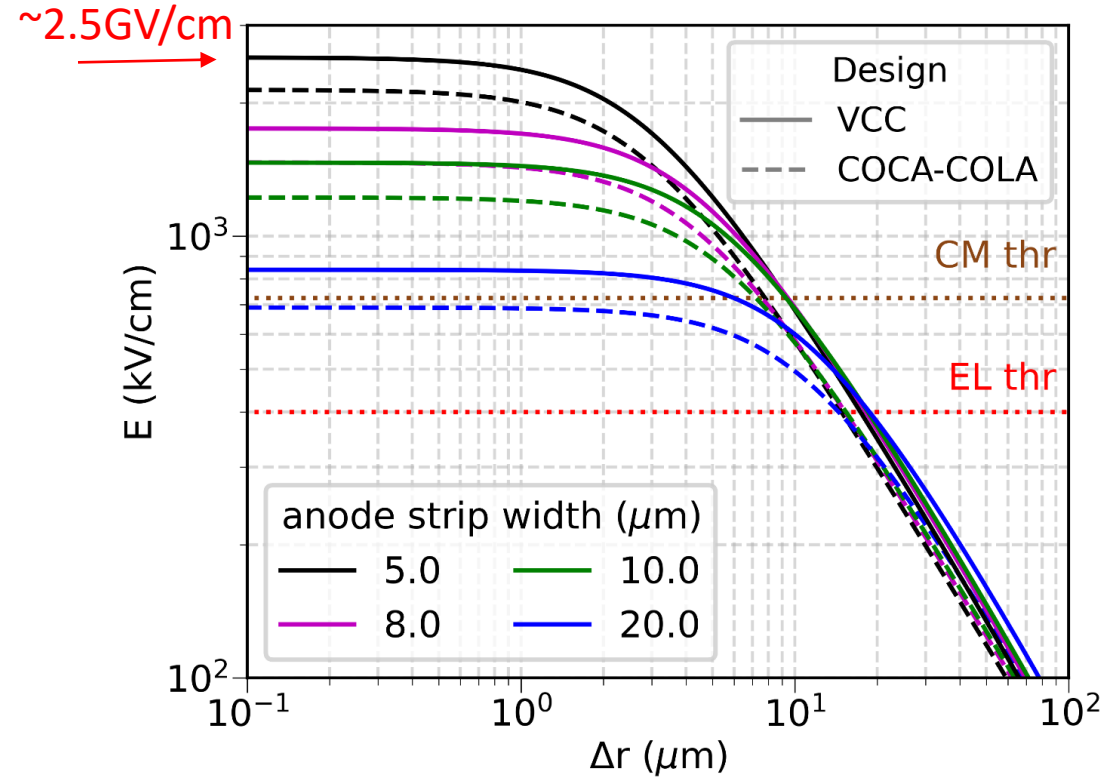
Strip thickness 1-10 nm
 Anode strips 8 μm wide
 COCA-COLA cathode strips 200 μm wide
 MSGC cathode strips 400 μm wide

Field vs strip width

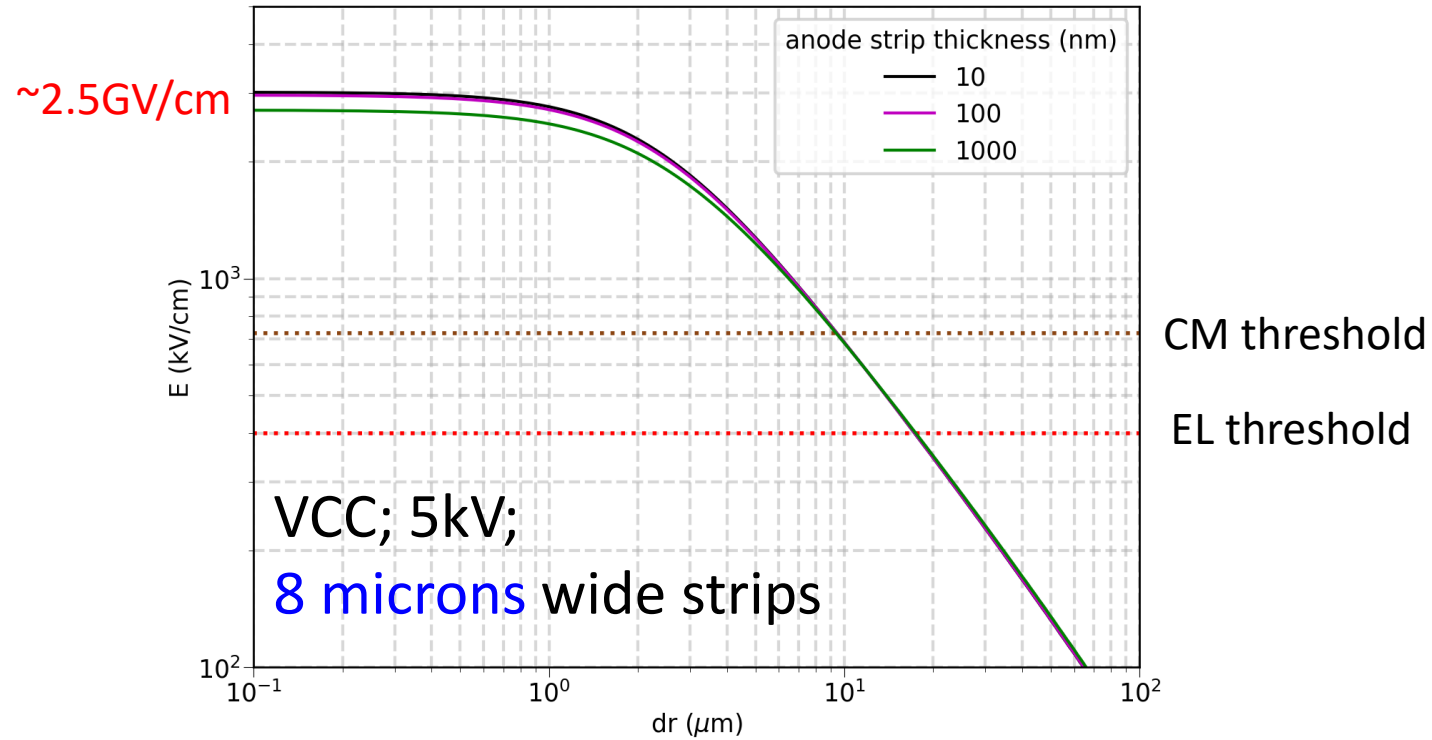
Tested MSGC: 8 micros/2kV



current VCC: 5 micros/5kV



VCC: Field vs Δr – dependence on strip thickness

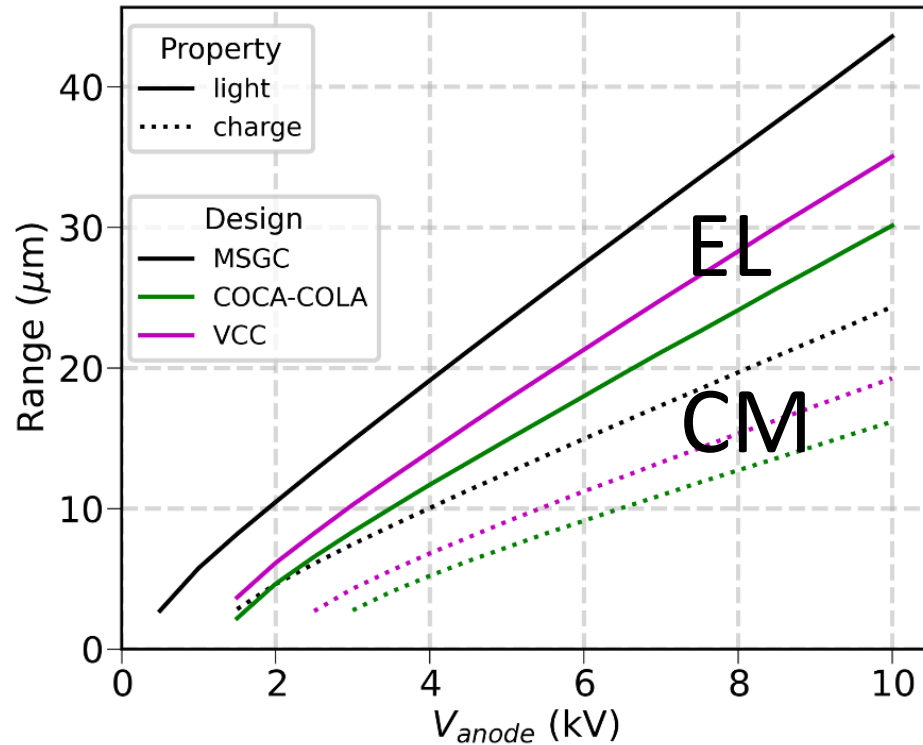


Low dependence of field on strip thickness

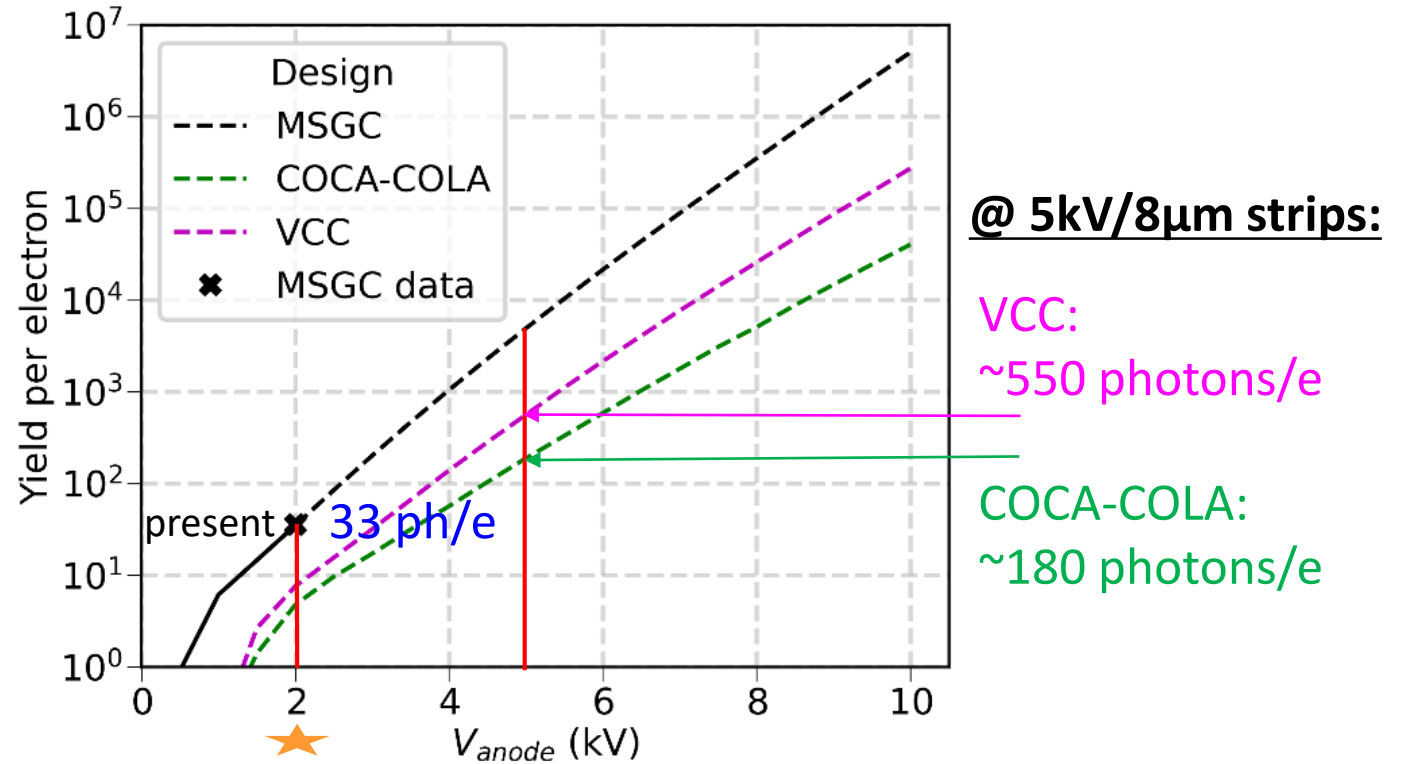
Model* Predictions

Martinez Lema <https://arxiv.org/abs/2308.08314>

Range for CM & EL above $E_{\text{threshold}}$

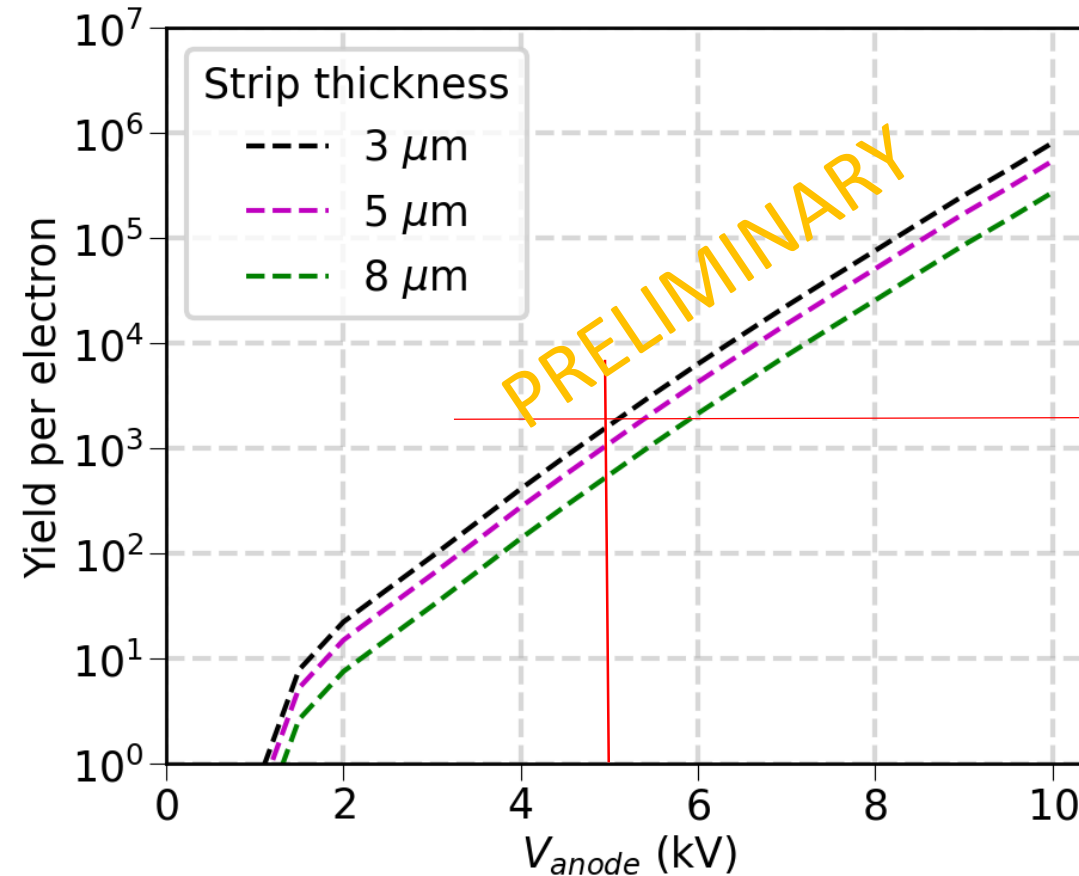


Photoyield



* Model: Aprile JINST 2014

VCC: photoyield – strip width

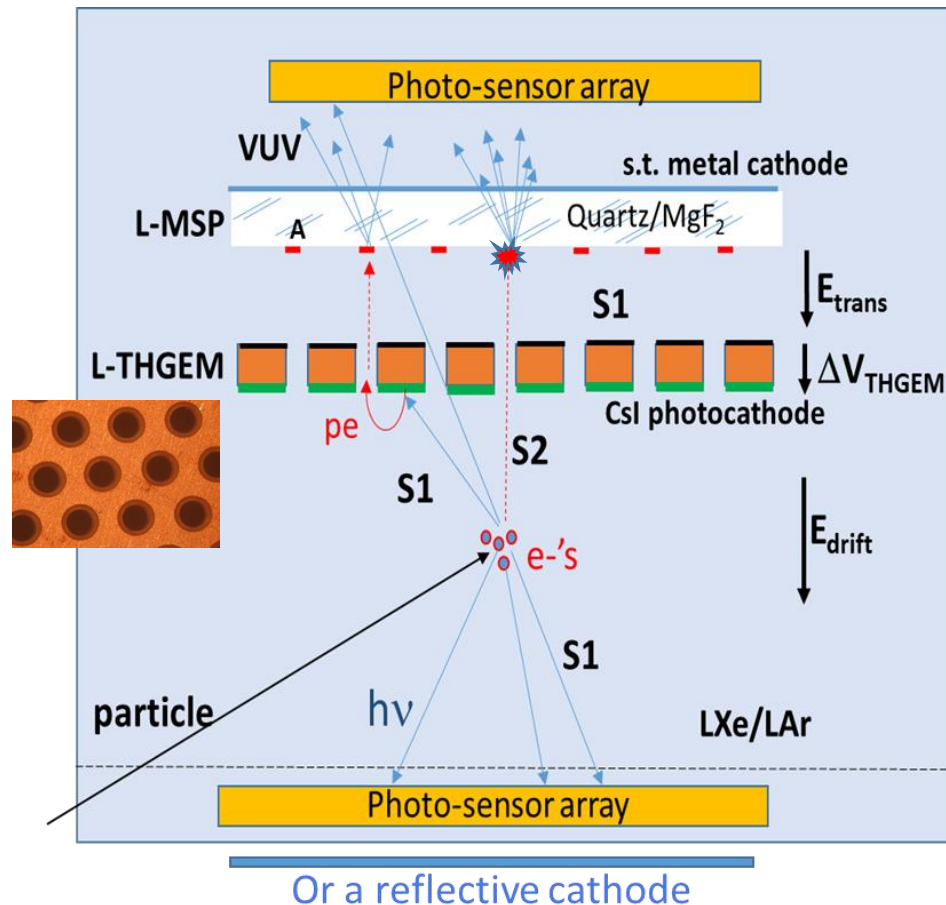


3micron strips/5kV:
~ 1700 photons/e

S2 + S1
“dreams”

e & $h\nu$ multiplication with cascaded microstructures

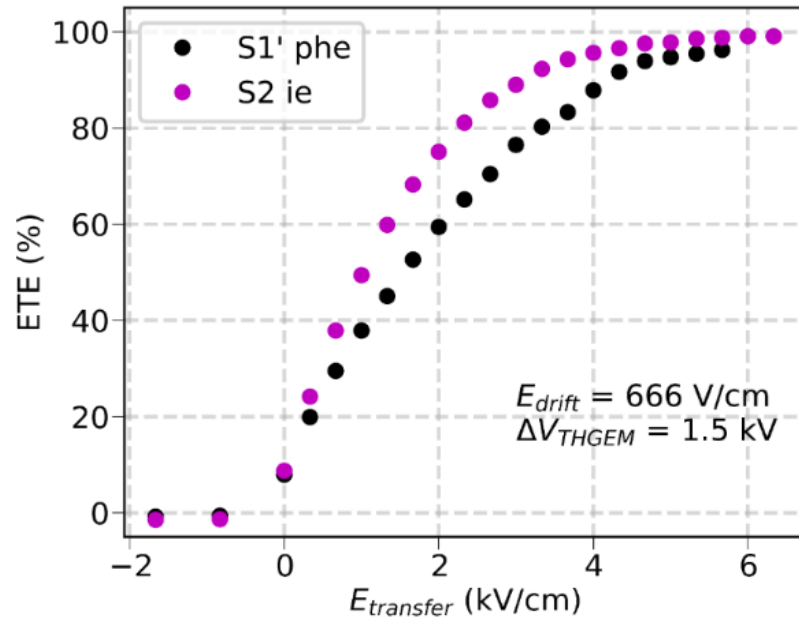
Combined S1 & S2 detection



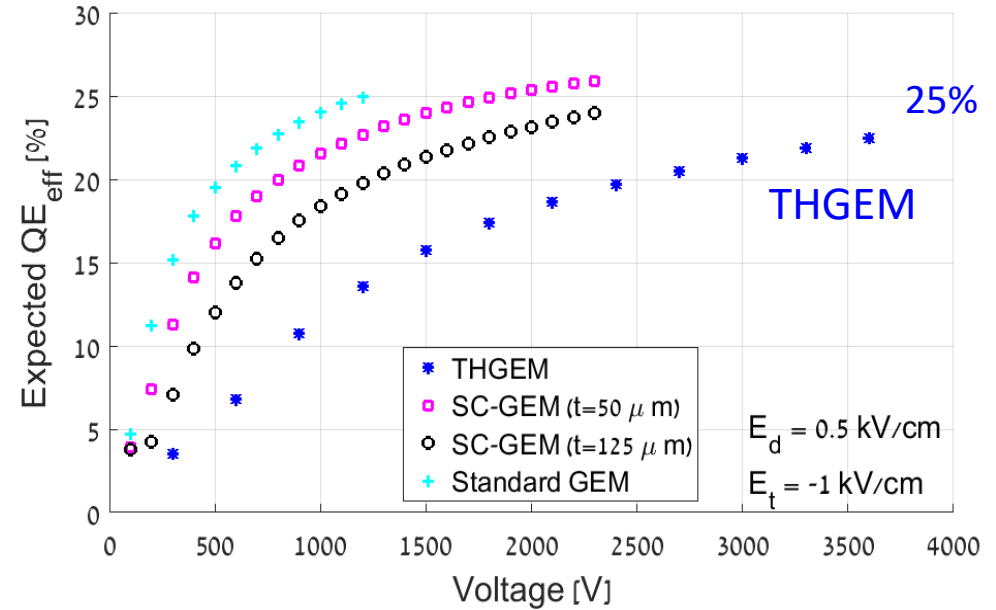
- 2-stage single-phase TPC with CsI-coated perforated electrode (L-THGEM) followed by a L-MSP
- **S2 e & S1 VUV-pe** collected into L-THGEM holes & efficiently transferred to the L-MSP.
- EL+CM VUV photons emitted at the microstructure - detected above, by top photo-sensors.
- A fraction of S1 photons – detected by bottom photo-sensors or reflected by a reflective-cathode to the CsI.
- Option: top L-THGEM surface can be reflective or WLS-coated (→ visible-range photo-sensors, glass substrate).

THGEM: Electron transfer and CsI Quantum Efficiency in LXe

Experimental Transfer Efficiency of e^- and pe^- through THGEM holes in LXe.

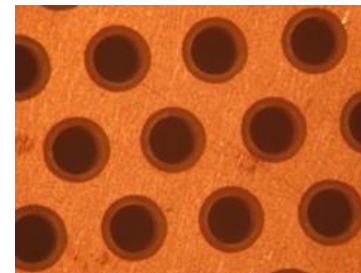
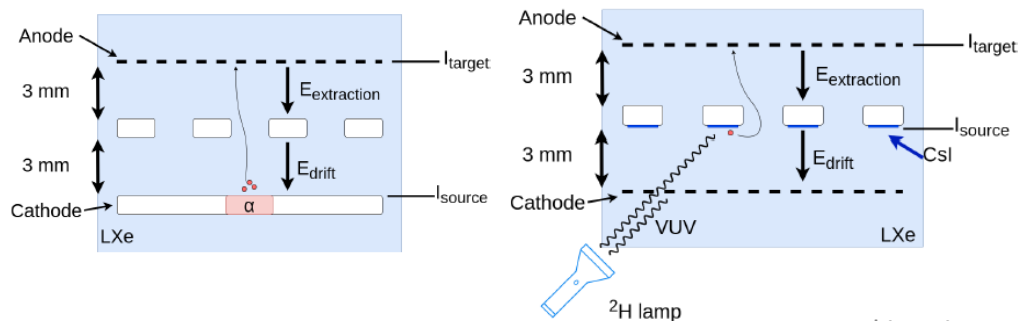


QE_{eff} of CsI in LXe



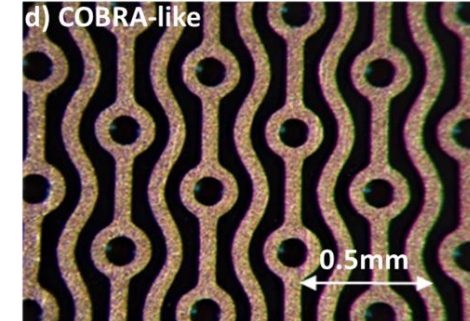
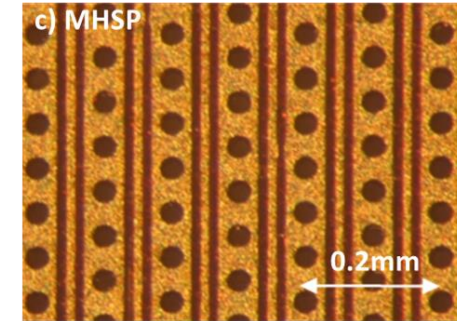
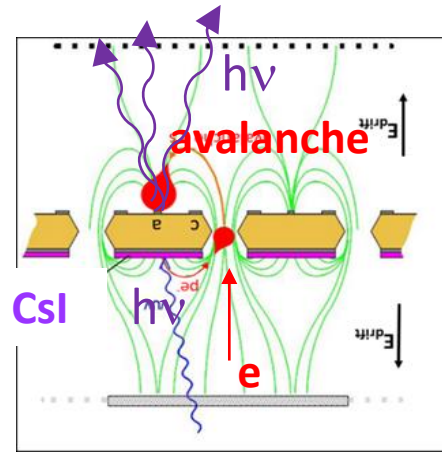
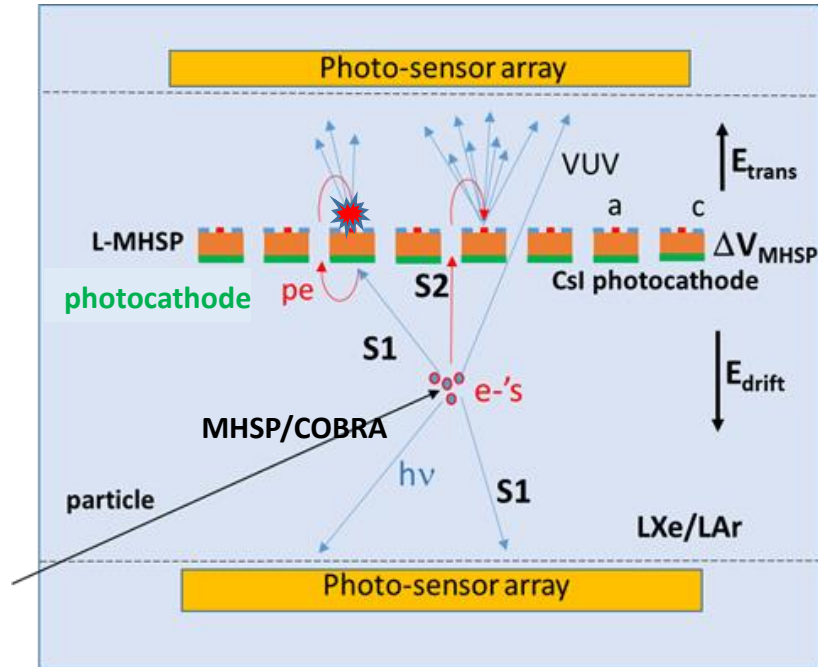
Martinez-Lema 2023 <https://doi.org/10.1088/1748-0221/19/01/P01030>

Erdal 2021 https://jinst.sissa.it/jinst/theses/2021_JINST_TH_002.jsp



Amos Breskin micro-structured single-phase multipliers - Nagoya - 14.2.2024

Single-phase with single Micro Hole & Strip Plate (MHSP)

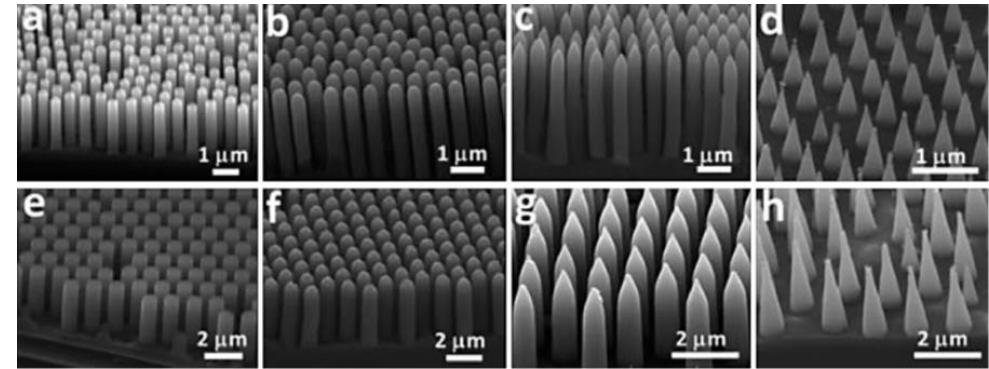
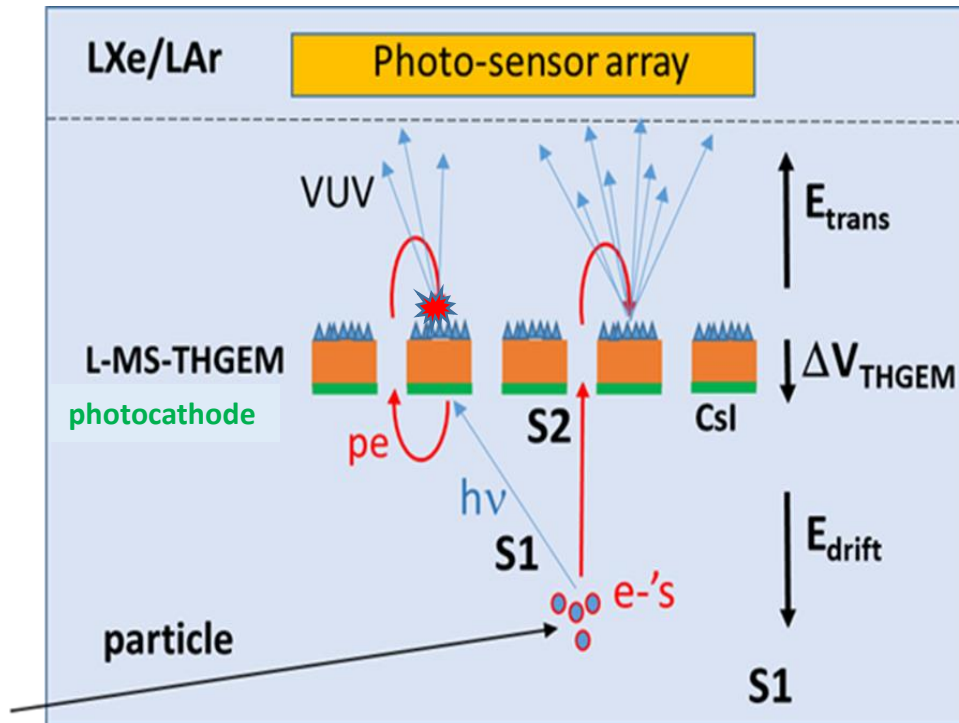


MHSP: Veloso, Rev Sci. Instr. 71, 2371 (2000)
<https://doi.org/10.1063/1.1150623>

Current technologies → few- μm strips possible

- A single-phase TPC with CsI-coated **L-MHSP** on insulating substrate.
- S2 e & VUV pe collected into the L-MHSP holes & collected by MHSP anode strips.
- **ALL** VUV photons (EL + CM): detected by the top photo-sensors.
- Other fraction of S1 photons - detected by bottom photo-sensors or reflected to the CsI surface (not shown).

Single-phase with Micro-structured electrode



Hao Lin <https://doi.org/10.1039/C3TA11889D>

- Single-phase TPC with micro-structured THGEM top surface (**L-MS-THGEM**), under-coated with CsI.
- S2 e & S1 VUV pe collected into the holes towards the micro-structured top surface
- VUV photons emitted by EL + CM at the “anode tips”, are detected by top photo-sensors.
- Other fraction of S1 photons are detected by bottom photo-sensors or reflected surface(not shown).

Summary & Outlook

AIMS:

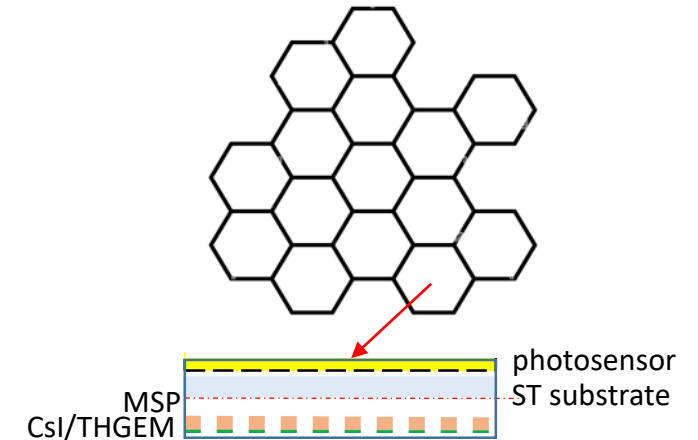
- Single-element and cascaded micro-structured multipliers for S2 & S1+S2

POTENTIAL ADVANTAGES:

- Potentially Robust & Modular
- Intense (**100's of photons/e**) & fast S2(&S1) light flashes
 - ➔ permits “high dark-noise” photosensors (SiPM, SPAD, ...)
 - ➔ Potentially reduces detection threshold

R&D:

- Currently: **VCC** light-emission studies in LXe (soon: LAr).
- Tasks (LAr, LXe): maximizing photoyield, stability – electrical & photocathode in NL, physical parameters in LXe/LAr, multiplier/sensor technologies, radio-purity etc.



Example: cascaded S1/S2 sensor module

Open to collaborations – seeking for students/postdocs!